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Novel Design of 8T Ternary SRAM for Low Power Sensor System

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Abstract

In this study, we propose a novel 8T ternary SRAM that can process three logic values (0, 1, and 2) with only two additional transistors, compared with the conventional 6T binary SRAM. The circuit structure consists of positive and negative ternary inverters (PTI and NTI, respectively) with carbon-nanotube field-effect transistors, replacing conventional cross-coupled inverters. In logic '0' or '2,' the proposed SRAM cell operates the same way as conventional binary SRAM. For logic '1,' it works differently as storage nodes on each side retain voltages of $V_{DD}/2$ and V_{DD} , respectively, using the subthreshold current of two additional transistors. By applying the ternary system, the data capacity increases exponentially as the number of cells increases compared with the 6T binary SRAM, and the proposed design has an 18.87% data density improvement. In addition, the Synopsys HSPICE simulation validates the reduction in static power consumption by 71.4% in the array system. In addition, the static noise margins are above 222 mV, ensuring the stability of the cell operation when V_{DD} is set to 0.9 V.

Keywords: Multivalued logic, CNTFET, SRAM, Ternary logic circuits

1. INTRODUCTION

With the emergence of artificial intelligence (AI) and Internet of Things (IoT) technologies, the importance of SRAM has received recurrent attention [1-3]. SRAM is located close to the processor and is a critical solution to data bottlenecks owing to its fast data access. Additionally, because of its simple operating mode and mature technology, it has become a widely used memory device, not only in microprocessors but also in various applications. Among them, SRAM is applied to numerous sensor technologies, such as wearable devices, image processing, and wireless devices [4-6]. Because the latest technologies require large amounts of data, combining sensors with them requires a low-power system while maintaining a small form factor.

However, conventional binary SRAM, which uses six transistors per *bit*, has a large cell size compared with its data capacity. Despite ongoing efforts in device scaling, there remain limitations in processing significant amounts of data [7]. As a

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breakthrough, multivalued logic (MVL) can improve the data capacity compared with a binary system [8]. In digital circuits, a multidigit system can be used by dividing the voltage levels into more than high/low levels. As the first step in MVL logic development, three-valued (ternary) logic has been studied in various fields.

In particular, carbon nanotube field-effect transistors (CNTFET) have been studied for use in ternary-logic systems [9]. As transistor technology scales down, complementary metal-oxide-semiconductor (CMOS) technology faces limitations owing to its short-channel effects and leakage power dissipation [10,11]. By contrast, CNTFETs can be scaled down to a sub-10 *nm* dimension at room temperature through the ballistic transport of charge carriers. In addition, it is suitable for MVL because it is easy to modulate the threshold voltage by adjusting the chirality vector of the CNTs.

With the ternary-logic system, a memory device can represent three values in a single cell. The simplest approach to implementing a ternary SRAM is to connect two standard ternary inverters (STIs) and store data in their feedback loops. Research on the 14T ternary SRAM using CMOS-based 6T STIs is a representative example [12]. However, this approach is inefficient in terms of the number of transistors relative to the data capacity. The data capacities of the binary and ternary systems are 2^n and 3^n for *n* cells, respectively. Therefore, to process the same amount of data, ternary requires only approximately $log_32 \approx 0.63 \times as$ many cells as binary. Simultaneously, $0.63 \times 14/6 \approx 1.47 \times$

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Fig. 1. (a) Data density of MVLs. (b) Schematics of PTI and NTI. (c) Schematic symbols and threshold voltage for LVT, RVT, and HVT of CNTFET

transistors are needed, which implies more transistors are required to process the same data as shown in Fig. 1 (a).

This paper proposes an 8T ternary SRAM cell based on the CNTFET technology [13,14]. This design requires only $0.63 \times 8/6 \approx 0.84 \times$ transistors compared to binary, effectively increasing the data density. The power consumption of the entire system can also be reduced by using fewer cells to process the same data. Furthermore, the design reduces power consumption by utilizing a subthreshold current. We validated the functionality and performance using HSPICE simulations by comparing our design not only with the 6T binary SRAM but also with other ternary SRAM models [12,15]. This study makes three contributions.

- · Lowest transistor count among ternary SRAM designs
- 18.87% data density improvement compared with 6T binary SRAM
- 71.4% reduction in static power consumption compared with 6T binary SRAM.

2. EXPERIMENT

2.1 Preliminary

2.1.1 Ternary Logic

Among MVL systems, ternary logic is a numerical system with three logical values represented as (0, 1, 2) or (-1, 0, +1), known as unbalanced and balanced ternary logic, respectively. The three values indicate (*GND*, $V_{DD}/2$, V_{DD}). This study focuses on unbalanced ternary logic. Implementing a ternary logic state requires two distinct multi-threshold voltage values [8]; in our case, we employed a low threshold voltage (LVT) and high threshold voltage (HVT) without a regular threshold voltage (RVT) in the cell. Voltage values lower than the LVT correspond to logic '0,' values higher than the HVT correspond to logic '2,' and the voltage levels between these thresholds correspond to logic '1.'

To process the middle logic state '1', other types of inverters exist. As shown in Fig. 1 (b), a positive ternary inverter (PTI) and a negative ternary inverter (NTI) are composed of two types of transistors. While receiving logic '0' and '2' as inputs, both inverters output the inverted values '2' and '0', respectively. However, when the input is logic '1', PTI outputs '2', and NTI outputs '0'.

2.1.2 CNTFET

CNTFET is a type of field-effect transistor that uses the carbon nanotube as a channel from the source to the drain [13,14]. Fig. 1 (c) shows schematics of MOSFET-like CNTFETs. They exhibit semiconducting or metallic properties based on the angle of atomic arrangement, known as the chirality vector, which is expressed as a pair of integers (*n* and *m*). The chirality vector not only determines the electronic properties but also influences the tube diameter and threshold voltage of the CNTFET. The relationship between the parameters can be defined using the following equation, where m = 0:

$$\frac{V_{th2}}{V_{th1}} = \frac{D_{CNT2}}{D_{CNT1}} = \frac{n_2}{n_1}$$
(1)

Typically, the n- and p-type CNTFETs employ three threshold voltages: LVT, RVT, and HVT. In this study, the chirality vectors were set as (17, 0), (13, 0), and (8, 0) for the respective thresholds. For the n-type CNTFETs, the corresponding values were 0.323, 0.428, and 0.687 *V*. The SRAM cell utilizes LVT and HVT, whereas the peripheral circuitry employed for operational verification uses all three types of transistors.

2.1.3 Ternary SRAM Cells

Conventional binary SRAM cells store 1 *bit* of data per cell, whereas ternary SRAM cells store 1 *trit* of data. Therefore, the amount of data that can be processed per n cells is 2^n for binary and 3^n for ternary systems, respectively. This implies that the data capacity of the ternary systems increases exponentially as the total array size increases. Conversely, when two types of logical systems process the same 2^n data points, the number of cells required for the ternary system compared with the binary system can be expressed by the following equation:

$$\frac{k}{n} = \frac{\log 2}{\log 3} \approx 0.63 \tag{2}$$

To implement ternary SRAM cells, several studies have utilized the structure of cross-coupled inverters with various types of STIs. However, while conventional binary inverters consist of two transistors per *bit*, STIs require six or more transistors to implement one *trit*. Consequently, unlike binary SRAM, which employs only six transistors per cell, ternary SRAM cells require a significantly higher number of transistors. This leads to inefficiencies in the memory array density.

In [12], an SRAM trit cell with 14 transistors was designed based on 6T STIs with CMOS technology. However, to process 2^n data points, a binary SRAM requires *n* cells, thereby necessitating 6*n* transistors. By contrast, ternary SRAM can only process $n \times log_3 2$ cells. Thus, it is effective when the number of transistors per cell is less than $6 \times log_2 3 \approx 9.51$.

2.2 Proposed Design

Conventional SRAMs store data in a symmetric feedback loop structure of cross-coupled inverters. However, in ternary systems, STIs require more than six transistors, resulting in transistor count overhead. Without conventional structures, an SRAM trit cell design implemented with only eight transistors based on CNTFETs was proposed in this study.

As shown in Fig. 2, it consists of PTI, NTI, and two additional transistors, M1 and M2, which form the structure of an asymmetric feedback loop. When the stored data of the Q node is '0' or '2,' it works the same as conventional SRAMs. This is because the same values are input to M1 and M2, which operate as general inverters. However, when the data are '1,' PTI and NTI lead to differing inputs of '2' and '0' to M1 and M2, respectively, which results in both transistors turning off. Subsequently, the feedback loop continues to operate because of the subthreshold current.



Fig. 2. Schematic of proposed 8T ternary SRAM

2.2.2 $V_{DD}/2$ Operations

This section describes the operations at $V_{DD}/2$, including HOLD, READ, and WRITE. For the HOLD operation, it was assumed that the Q node retained a *trit* of '1'. When $V_{DD}/2$ was applied to the inputs of PTI and NTI, the gate of the p-type M1 transistor received V_{DD} , whereas the gate of the n-type M2 received *GND*. Subsequently, node Q maintained the logic state '1' through the subthreshold currents from each transistor, effectively sustaining this value through the feedback loop.

For the READ operation, the initial values of TL/TLB were forced to $V_{DD}/2$ using a pre-charge circuit. The WL node, which was the gate of the access transistors, received $V_{DD}/2$ instead of V_{DD} . This prevented the flipping of the stored data '1' corresponding to $V_{DD}/2$ while the WL voltage was raised. When *trit* '1' was stored at the Q node and '2' at the QB1 node, both ntype access transistors remained turned off at $V_{GS} = 0$ V and no potential change occurred at the TL/TLB nodes. Thus, the sense amplifier output $V_{DD}/2$, which corresponded to '1'.

In WRITE, V_{DD} was applied to the WL node. Assuming that '0' was initially stored before writing *trit* '1', nodes Q and QB1 had voltages of *GND* and V_{DD} , respectively. Because there was PTI between the data input terminal and TLB node inside the write driver, '1' and '2' were applied to the TL and TLB nodes, respectively. Consequently, the right access transistor turned off with $V_{GS} = 0V$, whereas the left access transistor was activated, forcing the Q node to '1'. Consequently, through PTI and NTI in the cell, nodes QB1 and QB2 stored '2' and '0', respectively.

3. RESULTS AND DISCUSSION

3.1 Simulation Set-up

A 32 nm Stanford CNTFET model [13,14] was used to design

the proposed 8T SRAM trit cell with a supply voltage of 0.9 *V*. The static noise margin (SNM) was assessed by altering the DC sweep voltage in increments of 1 mV to detect the flips. The power consumption and delay of the SRAM cells were measured via transient simulations using Synopsys HSPICE. The input transient time was set to 10 *ps* with rise and fall delays of 1 *ps* each, totaling 420 *ns*. Four STI gates were used as fanout loads for the transient simulations of the proposed design with full circuitry. For performance comparison, existing designs, including the 6T binary SRAM and 14T, 20T, and 24T ternary SRAM models, were also designed using the CNTFET and evaluated.

3.2 Performance Comparison

3.2.1 Static Noise Margin

The SNM is an indicator of the amount of noise allowed in the input inside the cell to maintain a stable state [16]. The measured SNMs are shown in Fig. 3. Each bar graph represents the SNM values based on V_{DD} , $V_{DD}/2$, and GND. In the case of the 6T cell, the highest value was 341 mV for both V_{DD} and GND, but it was based on 1 *bit* of data, and the area outside the margin was 218 *mV*. In the case of ternary SRAM cells, three logic values were distinguished based on the same power-supply voltage: the proposed 8T ternary SRAM design had the smallest area outside the margin, at a total of 6 *mV*. In addition, the noise margin values were 225, 222, and 225 *mV*, which had the smallest deviation among the three logic states. This indicated that the proposed design has the most stable tolerance to noise among the ternary SRAM models.

3.2.2 Power & Delay

To evaluate the power and delay measurements, all the data changes were measured for each operation. The measured values were compared with those of other models using the average value. Table 1 lists the average power consumption values for each operation. The proposed 8T ternary SRAM consumed the lowest power among all the comparison models, and compared to the binary SRAM, it exhibited improved power efficiencies of 54.7%, 17.5%, and 34.6% for the HOLD, READ, and WRITE operations, respectively. Moreover, this result was the measurement of a single cell. For the same data, a ternary system uses a lower cell count than a binary system. Consequently, as the memory array expands, the percentage reduction in power consumption increases. The power



Fig. 3. Static noise margin measurements

Table 1. Average power consumption

Avg. Power [<i>uW</i>]	6T (1 <i>bit</i>)	8T (1 <i>trit</i>)	14T (1 <i>trit</i>) [12]	20T (1 <i>trit</i>) [15]	24T (1 <i>trit</i>) [15]
HOLD	135	61.19	113.43	95135.4	6084.9
READ	0.789	0.651	0.657	0.811	0.521
WRITE	0.026	0.017	0.034	0.077	0.497



Fig. 4. Full circuitry of 8T ternary SRAM

consumption of the HOLD operation, which is the state of data storage, refers to the static power consumption. With cell

Table 2. Average delay

		-						
Avg.	(T	077	14T	20T	24T			
Delay	61	81	(1trit)	(1trit)	(1trit)			
[ps]	(1bit)	(1 <i>trit</i>)	[12]	[15]	[15]			
READ	117	483.5	583.5	669	1150.5			
WRITE	3.07	10.86	25.27	10.62	24 033			
WILLE	5.07	10.00	20.27	10.02	21.055			
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0 - 0								
0	0 60	120	180 240	300 3	60 420			
Time [ns]								

Fig. 5. Transient simulation results

reduction through ternary logic, the static power consumption can be reduced by $54.7 \times log_3 2 \approx 71.4\%$ in the array system. Table 2 lists the average delay values for each operation. The proposed design had a slower speed than the binary SRAM. However, compared to other ternary SRAM models, it exhibited the lowest value in the READ operation and was also close to the fastest 20T cell in the WRITE operation.

3.3 Transient Simulations

Peripheral circuits were designed to verify the functionality of the proposed ternary SRAM cell design, as shown in Fig. 4. The write driver enforced the TL/TLB nodes to align with the input data during the WRITE operation. The pre-charge circuit forced the TL/TLB nodes to $V_{DD}/2$ to facilitate the READ operation. Finally, the sense amplifier received the potential from the TL/ TLB nodes and delivered it to the output node based on the potential difference between the two inputs.

As shown in Fig. 5, the data were input in the sequence $0 \rightarrow 0$ $1 \rightarrow 2 \rightarrow 1 \rightarrow 0 \rightarrow 2 \rightarrow 0$ ', with WRITE and READ operations performed for each data value. This approach ensured the comprehensive testing of the functionality of the SRAM cell across its entire operational range. To write data 0, 1, or 2 to the Q node, the write driver was activated when the WRITE signal was turned on. After the TL and TLB nodes were charged to (0, 2), (1, 2), or (2, 0), these data were stored in the Q/QB1 node as soon as WL increased. In the READ scheme, the pre-charge circuit was activated when signal PRE was turned on, and both the TL and TLB nodes were set to $V_{DD}/2$. After WL reached the middle $(V_{DD}/2)$, the potential of the TL/TLB nodes was discharged or maintained at (0, 1), (1, 1), or (1, 0), depending on the data stored in Q/QB1. The potential difference of the corresponding voltage-level pairs was detected through the sense amplifier and output to the OUT node as 0, 1, or 2.

4. CONCLUSIONS

This study demonstrated the feasibility of ternary SRAM for sensor systems with small form factors and large-scale data. A ternary SRAM design with eight transistors based on CNTFETs was proposed. PTI, NTI, and two additional transistors were applied to the proposed SRAM for an asymmetric feedback loop. The practical efficacy of the 8T SRAM trit cell was demonstrated by comparing its data density with those of other SRAM models. The measurement of SNMs ensures stability in ternary-logic systems. The simulation results demonstrated the power consumption and delay improvement of the proposed ternary SRAM compared with previous ternary SRAM designs. Additionally, the reduction in static power consumption was described in comparison with binary SRAM in a memory array system. For the proposed design, the cell operation was demonstrated by simulation with peripheral circuits. As future research, it is expected to develop a ternary in-memory computing system with high energy efficiency based on the proposed SRAM cell.

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